

10/11/89

ISSUE CLASSIFICATION	
Class	Subclass

~~PATENT~~ NUMBER

U.S. UTILITY Patent Application

<p>O.I.P.E.</p> <p>SCANNED <i>IX 3</i> Q.A. <i>SP3</i></p>	<p>PATENT DATE:</p>
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APPLICATION NO. 09/854206	CONT/PRIOR	CLASS 438	SUBCLASS 724	ART UNIT 2812 T-735	EXAMINER T. Tran, B
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APPLICANTS

David Pecora

TITLE

Etch of silicon nitride selective to silicon and silicon dioxide
useful during the formation of a semiconductor device

PTO-2040
12/99

ISSUING CLASSIFICATION

[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) _____ (Date)			NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____	_____ (Primary Examiner) _____ (Date)			ISSUE FEE	
				Amount Due	Date Paid
<input type="checkbox"/> The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) _____ (Date)			ISSUE BATCH NUMBER	

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